

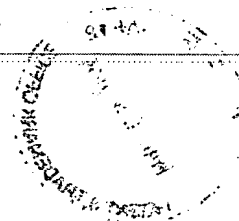
## PATENT ABSTRACTS OF JAPAN

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(54) COLLOIDAL SOLUTION OF METAL, AND MANUFACTURING METHOD OF THE SAME

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a colloidal solution of metal having high dispersion obtained by a simple manufacturing method, and showing high conductivity, and to provide a manufacturing method of the same.

SOLUTION: The colloidal solution of metal is made to contain a compound having at least one amino group and one carboxyl group.

## LEGAL STATUS

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